Technology Information	
Area	2
Title	Conditioning of residues from water treatment
Submitted by	NUKEM Technologies GmbH, in cooperation with ALD/FNAG

1. Overview of Technologies (features, specification, functions, owners, etc.)

The purification of contaminated water produces considerable volumes of high-active spent, loaded inorganic absorbers (zeolite like, silicagel, etc.), which for intermediate and final storage will be required to be conditioned.

A newly developed matrix, the IGM, offers unique advantages.

Waste, graphite and borosilicate glass are mixed together, introduced into a container, and subsequently subjected to vacuum, pressure (1.000 bar), and high temperature (1.000 °C). The industrially well-established Hot Isostatic Pressure HIP process may be applied.

The advantages of this system are:

- **No radiolysis:** Water content in product can be reduced as far as wanted by application of vacuum and heating for drying/gas removal,
- No Cs losses: (ie Zero!), since closed system during HIP,
- Volume reduction: by factor 2 (bulk Zeolite/IGM product 60 w% loaded),
- **High leaching stability:** due to low porosity and corrosion resistance of glass/ graphite combination,
- Heat dissipation: better than vitrified product, since graphite has higher heat conductivity compared to glass (and much better than hot-pressed pure Zeolite).
- 2. Notes (Please provide following information if possible.)

Technology readiness level (including cases of application, not limited to nuclear industry, time line for application):

- Lab-scale test have been done, followed by investigations of properties.
- The HIP process is well known and proven in conventional industry for the manufacturing of high dense ceramic compounds.
- HIP has been tested as compaction method for different radioactive wastes in different matrices e.g. the consolidation of Plutonium in UK by NNL.
- The IGM matrix is a new development for radioactive waste embedding. The manufacturing of IGM by HIP has already been proven with inactive waste simulants.

## Challenges

The process may have to be adapted for high radiation environments.

Others (referential information on patent if any)

Patents: JP 4944276 B2 2012.5.30, JP 5237475 B2 2013.7.17